	Application No.	Applicant(s)	
Notice of Allowability	09/966,651 Examiner	ZHU ET AL. Art Unit	
	Edna Wong	1753	
The MAILING DATE of this communication All claims being allowable, PROSECUTION ON THE MERIT herewith (or previously mailed), a Notice of Allowance (PTOL NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATEN of the Office or upon petition by the applicant. See 37 CFR 1	S IS (OR REMAINS) CLOSED in L-85) or other appropriate commu- NT RIGHTS. This application is sull 1.313 and MPEP 1308.	this application. If not included nication will be mailed in due course. THIS	ive
 This communication is responsive to <u>Amendment A decomment</u>. The allowed claim(s) is/are <u>1,5-11,13,15,16,18 and 20</u> 			
3. The drawings filed on 28 September 2001 are accepted			
4. ☐ Acknowledgment is made of a claim for foreign prior a) ☐ All b) ☐ Some* c) ☐ None of the:	•	· (f).	
1. Certified copies of the priority documents	have been received.		
2. Certified copies of the priority documents	have been received in Application	No	
 Copies of the certified copies of the priorit International Bureau (PCT Rule 17.2(a 	•	in this national stage application from the	
* Certified copies not received:	•		
 Acknowledgment is made of a claim for domestic prior reference was included in the first sentence of the spe 	cification or in an Application Data	Sheet, 37 CFR 1.78.	
(a) The translation of the foreign language provisio			
 Acknowledgment is made of a claim for domestic prior in the first sentence of the specification or in an Applic 		121 since a specific reference was include	∌d
Applicant has THREE MONTHS FROM THE "MAILING DAT below. Failure to timely comply will result in ABANDONMEN	E" of this communication to file a T of this application. THIS THRE	eply complying with the requirements note E-MONTH PERIOD IS NOT EXTENDABL	d .E
7. A SUBSTITUTE OATH OR DECLARATION must be s INFORMAL PATENT APPLICATION (PTO-152) which			
8. CORRECTED DRAWINGS (as "replacement sheets") (a) including changes required by the Notice of Drafts		(PTO-948) attached	
1) ☐ hereto or 2) ☐ to Paper No			
(b) ☐ including changes required by the proposed draw	ing correction filed, which	has been approved by the Examiner.	
(c) ☐ including changes required by the attached Exam	iner's Amendment / Comment or	n the Office action of Paper No	
Identifying indicia such as the application number (see 37 C each sheet. Replacement sheet(s) should be labeled as suc			
9. DEPOSIT OF and/or INFORMATION about the cattached Examiner's comment regarding REQUIREMENT FO			
Attachment(s)			
1 Notice of References Cited (PTO-892)	5☐ Notice of Info	mal Patent Application (PTO-152)	
2 Notice of Draftperson's Patent Drawing Review (PTO-94	•	nmary (PTO-413), Paper No	
3 Information Disclosure Statements (PTO-1449 or PTO/S Paper No	SB/08), 7∏ Examiner's Ai	mendment/Comment	
4 Examiner's Comment Regarding Requirement for Depos	sit 8⊠ Examiner's Si	atement of Reasons for Allowance	
of Biological Material	9 <mark>□</mark> Other .	Somalway	
		Edna Wong Primary Examiner Art Unit: 1753	

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REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance:

Claims 1 and 5-11 are allowable over the prior art of record because the prior art does not teach or suggest a method of forming an electrically conductive structure on a substrate, the method comprising the steps of (a) forming and (b) forming as presently claimed, esp., the combination of (iv) cyclically applying the first current and the second current at a frequency of between about thirty hertz and about one hundred and thirty hertz and (v) wherein the second current density of the second current is between about two times and about four times the first density of the first current.

Claims 13 and 15-16 are allowable over the prior art of record because the prior art does not teach or suggest a method of forming an electrically conductive structure on a substrate, the method comprising the steps of (a) forming, (b) forming and (c) forming as presently claimed, esp., the combination of (iii) applying a second current to the substrate at a reverse bias and a second density for a second duration, where the second duration corresponds to a replenishment time of the plating solution in the etched feature, wherein the second density of the second current is between about two times and about four times the first density of the first current and (v) cyclically applying steps (ii) and (v) at a frequency of between about thirty hertz and about one hundred and thirty hertz.

Claims **18 and 20** are allowable over the prior art of record because the prior art does not teach or suggest a method of forming an electrically conductive structure on a

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substrate, the method comprising the steps of (a) forming and (b) forming as presently claimed, esp., the combination of (iv) applying a second current to the substrate at a reverse bias and a second density for a second duration, wherein the second density of the second current is between about two times and about four times the first density of the first current and (v) cyclically applying the first current and the second current at a frequency of between about thirty hertz and about one hundred and thirty hertz.

The prior art does not contain any language that teaches or suggests the above.

Woo et al. do not teach cyclically applying the first current and the second current at a frequency of between about thirty hertz and about one hundred and thirty hertz.

Taylor et al. do not teach applying a second current to the substrate at a reverse bias and a second density for a second duration, wherein the second density of the second current is between about two times and about four times the first density of the first current.

Dubin et al. do not teach cyclically applying the first current and the second current at a frequency of between about thirty hertz and about one hundred and thirty hertz.

Therefore, a person skilled in the art would not have been motivated to adopt the above conditions, and a prima facie case of obviousness cannot be established.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on

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Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Edna Wong whose telephone number is (703) 308-3818. The examiner can normally be reached on Mon-Fri 7:30 am to 5:00 pm, alt. Fridays off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen can be reached on (703) 308-3322. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-1495.

Edna Wong
Primary Examiner
Art Unit 1753

EW November 24, 2003